

**NATIONAL PHASE  
UTILITY APPLICATION**

Attorney Docket No.: SHIGA7.049APC  
First Named Inventor: Yasushi Washio  
Int'l Application No.: PCT/JP2004/017398  
Int'l Filing Date: November 18, 2004  
Priority Date Claimed: December 1, 2003 and September 13, 2004  
Title: THICK FILM PHOTORESIST COMPOSITION AND  
METHOD OF FORMING RESIST PATTERN  
Express Mail Label No.: EV 465565784 US

Direct all correspondence to Customer No.: 20995

Date: May 4, 2006  
Page 1 of 2

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Alexandria VA 22313-1450

The following enclosures are transmitted herewith to be filed in the patent application of:

### Inventors:

1. Yasushi Washio 2. Koji Saito

#### **APPLICATION ELEMENTS:**

- (X) This is a FIRST submission of items concerning a filing under 35 U.S.C. § 371.
- (X) A copy of the International Application as published (35 U.S.C. § 371(c)(2)) is attached hereto.
- (X) A copy of the International Search Report for the International Application is attached hereto.
- (X) A copy of Form PCT/IB/304 for the International Application is attached hereto.
- (X) An English translation of the International Application as filed is not required.
- (X) Amendments to the claims of the International Application under PCT Article 19 (35 U.S.C. § 371(c)(3)) have not been and will not be made.
- (X) An Oath or Declaration signed by the inventors (35 U.S.C. § 371(c)(4)).

#### OTHER APPLICATION PARTS:

- (X) Preliminary Amendment in 5 pages.
- (X) Recordation form cover sheet and Assignment in 3 total pages (cover sheet & assignment).
- (X) Power of Attorney form and copy of assignment in 4 pages.
- (X) An Information Disclosure Statement and PTO/SB/08 equivalent listing references for consideration:
  - (X) Listing 3 references.
  - (X) Enclosing 1 reference.
- (X) Return prepaid postcard.

10/578398

AP20041110CTPTO 04 MAY 2006

**NATIONAL PHASE  
UTILITY APPLICATION  
Transmittal to the (DO/EO/US)  
Under 35 USC 371**

Attorney Docket No.: SHAKA20049AFC  
First Named Inventor: Toshiaki Washio  
Int'l Application No.: PCT/JP2004/017534  
Int'l Filing Date: November 18, 2004  
Priority Date Claimed: December 1, 2003 and September 13, 2004  
Title: THICK FILM PHOTORESIST COMPOSITION AND  
METHOD OF FORMING RESIST PATTERN  
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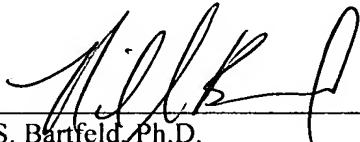
Date: May 4, 2006  
Page 2 of 2

**FILING FEES:**

<b>FEES CALCULATION</b>				
<b>FEES TYPE &amp; DETERMINATION</b>		<b>LARGE FEE</b>	<b>CALCULATION</b>	<b>TOTAL</b>
Basic Filing Fee under 1.492(a)		1631 (\$300)		\$300
Search Fee under 1.492(b) (enter one in TOTAL column)				
(1) USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)		1640 (\$0)		
(2) USPTO was the ISA (noncompliant claims)		1641 (\$100)		\$400
(3) Foreign Search Report Enclosed		1642 (\$400)		
(4) No Search Report Enclosed		1632 (\$500)		
Examination Fee under 1.492(c) (enter one in TOTAL column)				
(1) USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)		1643 (\$0)		\$200
(2) Non US IPEA or Noncompliant Claims		1633 (\$200)		
Excess Claims	9 - 20 = 0	1615 (\$50)	0 x 50 =	\$0
Excess Ind. Claims	1 - 3 = 0	1614 (\$200)	0 x 200 =	\$0
Multiple Dep. Claim		1616 (\$360)		\$360
Assignment		8021 (\$40)	1 x 40 =	\$40
			<b>TOTAL FEE DUE</b>	<b>\$1,300</b>
<b>TOTAL FEE PAID</b> (If Different Than Fee Due)				<b>N/A</b>

A check in the amount of \$1,300 to cover the Total Fee Due is enclosed.

The Commissioner is hereby authorized to charge any additional fees which may be required, now or in the future, or credit any overpayment to Account No. 11-1410.

  
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**1AP20 Rec'd PCT/PTO 04 MAY 2006**

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Alexandria, VA 22313-1450

**SUBMISSION BY "EXPRESS MAIL"**

**Attorney Docket No.** : SHIGA7.049APC  
**Applicant(s)** : Washio et al.  
**For** : THICK FILM PHOTORESIST  
COMPOSITION AND METHOD OF  
FORMING RESIST PATTERN  
**Agent** : Neil S. Bartfeld, Ph.D.  
**"Express Mail" Label No.** : EV 465565784 US  
**Date of Deposit** : May 4, 2006

The following documents are hereby placed into an Express Mail envelope bearing the number indicated above, which envelope is being deposited today with the U.S. Postal Service as Express Mail:

Transmittal letter; Preliminary Amendment in 5 pages; a copy of form PCT/IB/304 for the International Application; a copy of the International Search Report for the International Application; a copy of the published International Application; SIGNED Declaration and Power of Attorney (with copy of Assignment) in 4 pages; Recordation Form Cover Sheet and Assignment in 3 pages; Information Disclosure Statement, PTO Form PTO/SB/08 Equivalent with 1 reference enclosed; Check for Filing Fees; Return Prepaid Postcard.

The envelope, with the enclosures listed above, is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

This submission is being made in compliance with 37 CFR 1.10.

Vanessa C. Langer  
Name: Vanessa C. Langer  
Docketing Agent

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